

Title (en)
Lithographic apparatus

Title (de)
Lithographischer Apparat

Title (fr)
Appareil lithographique

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Application
EP 01306861 A 20010810

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Abstract (en)
[origin: EP1182684A2] Various options for improving throughput in an e-beam lithography apparatus are described. A slider lens moves in synchronism with the scanning motion of the electron beam. <IMAGE>

IPC 8 full level
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Cited by
EP1385192A3; EP1389794A3; US6878936B2; US7135677B2; US6914249B2; US6891168B2; US7888660B2; US7897943B2; EP1532650A1

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